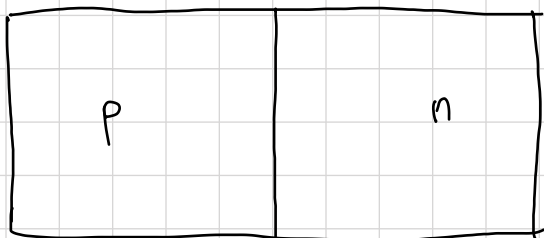


Lecture # 8

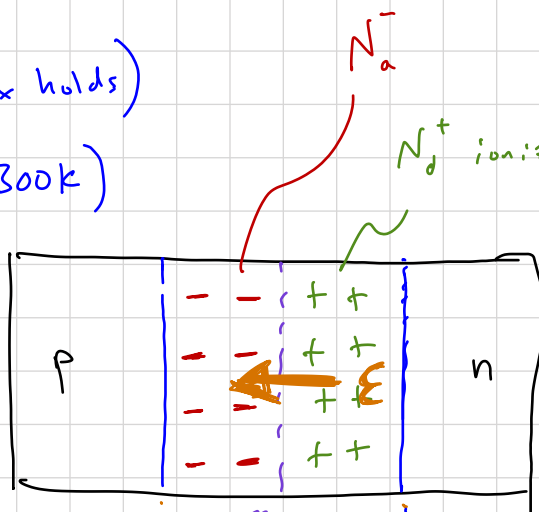
PN Junction Diodes

Conceptually, a pn junction is formed when a p-type S.C. region is brought into contact with an n-type region with an abrupt junction.
We will make the following assumptions in this analysis:

- ① Abrupt junctions (step junctions)
- ② Uniform doping
- ③ Nondegenerate (Boltzmann Approx holds)
- ④ fully ionized dopants ($T \sim 300K$)

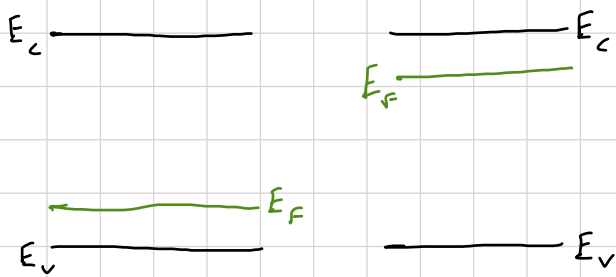


metallurgical junction



N_d^+ ionized positive dopants

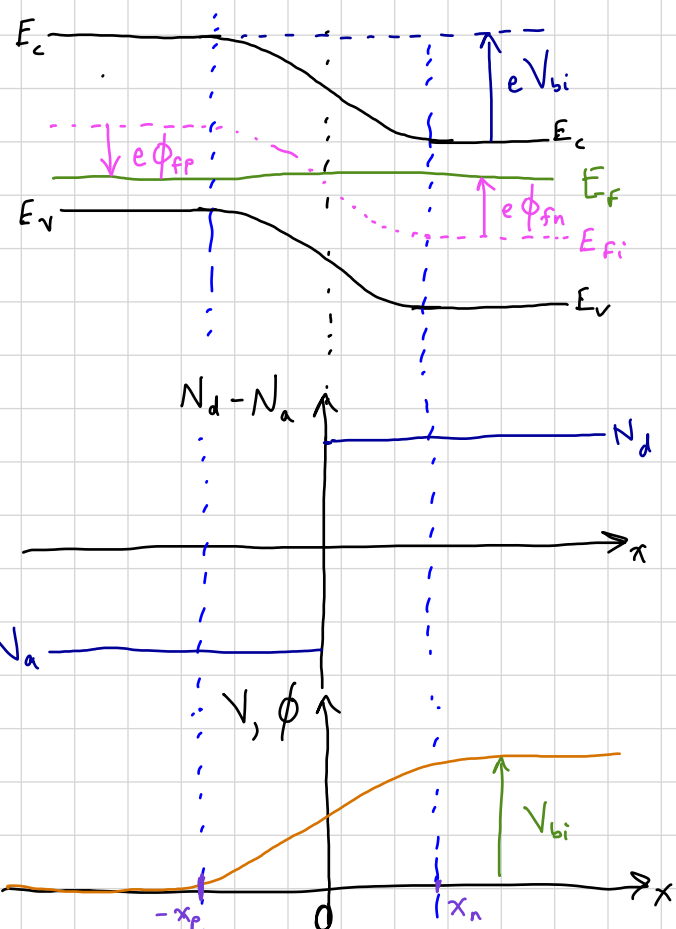
space charge region OR depletion width



Thermal EQ



Built-in Potential



$$V_{bi} = |\phi_{fn}| + |\phi_{fp}|$$

$$\text{Electric field: } \mathcal{E} = -\frac{dV}{dx}$$

Integrating across depletion region:

$$V_{bi} = -\int_{-x_p}^{x_n} \mathcal{E} dx = \int_{\phi(-x_p)}^{\phi(x_n)} d\phi = \phi(x_n) - \phi(-x_p)$$

Since EQ (no applied bias):

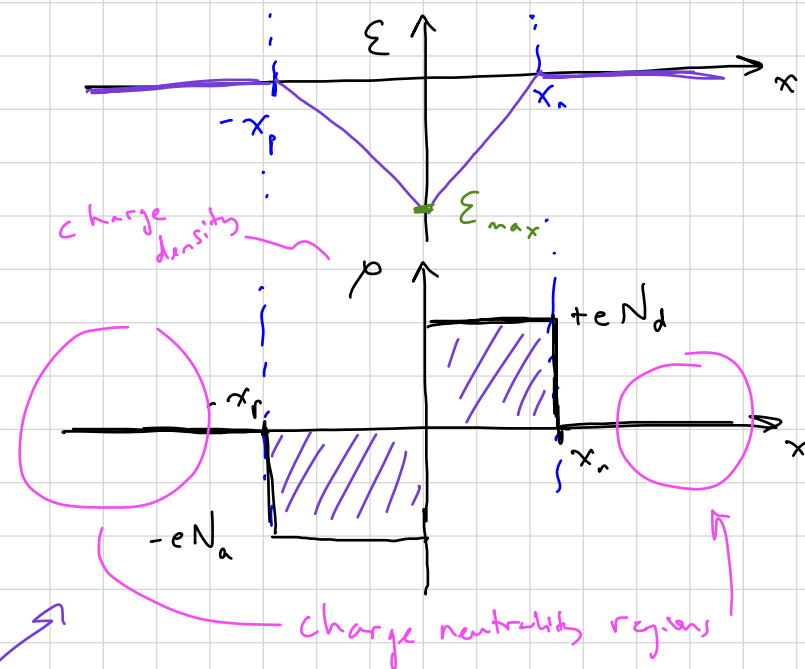
$$J_n = e\mu_n n \mathcal{E} + eD_n \frac{dn}{dx} = 0$$

solve for \mathcal{E} and use Einstein relation: $\frac{D_n}{\mu_n} = \frac{kT}{e}$

$$\mathcal{E} = -\frac{D_n}{\mu_n} \frac{d^2n/dx^2}{n} = -\frac{kT}{e} \frac{d^2n/dx^2}{n}$$

$$V_{bi} = -\int_{-x_p}^{x_n} \mathcal{E} dx = \frac{kT}{e} \int_{n(-x_p)}^{n(x_n)} \frac{1}{n} dn = \frac{kT}{e} \ln \left[\frac{n(x_n)}{n(-x_p)} \right]$$

Step junction, so: $n(x_n) = N_d, n(-x_p) = \frac{n_i^2}{N_a}$



$$V_{bi} = \frac{kT}{e} \ln \left(\frac{N_a N_d}{n_i^2} \right)$$

$\rightarrow V_t$ (thermal voltage)

★ NOTE: N_a and N_d from now on indicate doping on p-type or n-type side, respectively

Electric field

Poisson eqn = $\frac{dE}{dx} = \frac{\rho}{\epsilon_s \epsilon_0}$

book just gives ϵ_s but it is: $\epsilon_s \epsilon_0$
↑ relative dielectric constant

$$E = \int \frac{\rho(x)}{\epsilon_s \epsilon_0} dx$$

apply charge density conditions and get:

$$E = - \frac{e N_a}{\epsilon_s \epsilon_0} (x + x_p)$$

$$-x_p \leq x \leq 0$$

$$E = - \frac{e N_d}{\epsilon_s \epsilon_0} (x_n - x)$$

$$0 \leq x \leq x_n$$

Importantly at $x=0$: $N_a x_p = N_d x_n$

★ charges/cm² is = on both sides!!

→ potential in the junction: $\phi(x) = - \int E(x) dx$

$$\Rightarrow \phi(x) = \frac{e N_a}{2 \epsilon_s \epsilon_0} (x + x_p)^2$$

$$-x_p \leq x \leq 0$$

$$\phi(x) = \frac{e N_d}{2 \epsilon_s \epsilon_0} \left(x_n x - \frac{x^2}{2} \right) + \frac{e N_a}{2 \epsilon_s \epsilon_0} x_p^2$$

$$0 \leq x \leq x_n$$

Use this to develop another expression for V_{bi} :

$$V_{bi} = \left| \phi(x=x_n) \right| = \frac{e}{2 \epsilon_s \epsilon_0} (N_d x_n^2 + N_a x_p^2)$$

Space charge width (W) — depletion width → distance from $-x_p$ to x_n , since: $x_p = \frac{N_d}{N_a} x_n$

$$x_n = \left[\frac{2 \epsilon_s \epsilon_0}{e} \frac{N_a}{N_d (N_a + N_d)} V_{bi} \right]^{1/2}$$

$$x_p = \left[\frac{2 \epsilon_s \epsilon_0}{e} \frac{N_d}{N_a (N_a + N_d)} V_{bi} \right]^{1/2}$$

$$W = \left[\frac{2 \epsilon_s \epsilon_0}{e} \left(\frac{N_a + N_d}{N_a N_d} \right) V_{bi} \right]^{1/2}$$